

## Supplementary Materials for

## Kinetics of laser-induced melting of thin gold film: How slow can it get?

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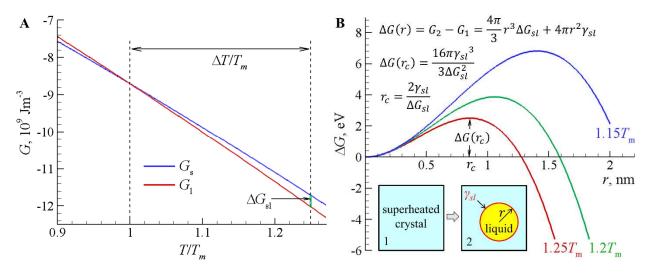
Supplementary Materials Figs. S1 to S7 References **Supplementary Material 1:** The limit of superheating of Au from the classical nucleation theory, figure S1.

The limit of superheating for the onset of massive homogeneous nucleation of liquid regions inside a superheated Au crystal can be estimated based on the classical nucleation theory (32, 78). The basic steps of the analysis of the limit of superheating are illustrated in fig. S1, where all plots are calculated using the experimental parameters of Au (31, 79). The difference in the volumetric free energy between the solid and liquid phases,  $\Delta G_{sl}$ , is increasing with the level of superheating above the melting temperature, as can be seen in fig. S1A. Using this temperature dependence of  $\Delta G_{sl}$  and the solid-liquid interfacial free energy of  $\gamma_{sl} = 132 \times 10^{-3} \text{ Jm}^{-2}$  (70,79), the change in the Gibbs free energy  $\Delta G$  due to the formation of a spherical nucleus with a radius r can be calculated as a function of r, fig. S1B. For any given level of superheating, the critical radius  $r_c$  that corresponds to the maximum of  $\Delta G(r)$  and the corresponding energy barrier  $\Delta G(r_c)$  can be calculated, as shown in fig. S1B.

The supercritical nuclei with  $r > r_c$  will grow spontaneously, and the rate of the nucleation can be expressed as  $R = R_0 \times exp(-\Delta G(r_c)/k_BT)$ , where  $k_B$  is the Boltzmann constant and  $R_0$  is a pre-factor weakly dependent on temperature. The nucleation rate required to completely melt a crystal within a melting time of  $\tau_m$  can be estimated as  $R \approx (2v\tau_m)^{-3}\tau_m^{-1}$ , where v is the velocity of the propagation of crystal-liquid interfaces generated by the nucleation. According to the results of MD simulations, the duration of the homogeneous melting at the limit of superheating is  $\tau_m \approx 10 \text{ ps} (13)$ , the maximum velocity of the melting front in metals is  $v \approx 500 \text{ m/s} (10)$ , and the limit of superheating at the onset of rapid homogeneous nucleation for Au is  $T^* \approx 1.25T_m$  (14). The values of  $\tau_m$  and v yield  $R \approx 10^{35} \text{ s}^{-1}\text{m}^{-3}$  as an estimate of the nucleation rate at the limit of superheating, while  $T^* = 1.25T_m$  corresponds to the volumetric free energy difference of  $\Delta G_{sl} \approx 3 \times 10^8 \text{ Jm}^{-3}$  (Fig. S1A) and the nucleation barrier of  $\Delta G(r_c) \approx 17.4 k_B T^* \approx 2.5 \text{ eV}$  (fig. S1B).

The prefactor  $R_0 \approx 4 \times 10^{42} \text{ s}^{-1}\text{m}^{-3}$  that reconciles the above estimations of R and  $\Delta G(r_c)$  at  $T^*$  is of the same order of magnitude as the theoretical estimation for the nucleation in condensed systems provided in Ref. (78),  $R_0 \approx k_B T/h V_a$ , where  $V_a$  is the atomic volume, and h is the Planck constant. The conclusion that the threshold-like onset of the massive homogeneous nucleation observed in MD simulations is consistent, at a semi-quantitative level, with the estimations based on the classical nucleation theory is remarkable. Indeed, the physical picture of the nucleation and

growth of spherical liquid regions cannot be expected to be valid up to  $T^*$ , when the critical radius  $r_c$  decreases down to less than a nanometer, Fig. S1B, and the distance the melting front propagates during the melting time of  $\tau_m = 10$  ps is less than 5 nm. Nevertheless, the kinetics of a more complex melting process revealed in the MD simulations, where a simultaneous formation of a large number of interconnected small liquid regions within the entire superheated volume is observed (10, 13, 14), is found to still be reasonably well described by the classical nucleation theory.



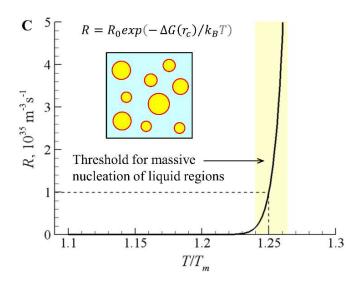


Figure S1. Three steps in the analysis of melting within the classical nucleation theory. (A) calculation of the volumetric free energy change  $\Delta G_{\rm sl}$  associated with melting, (B) free energy change  $\Delta G(r)$  due to the appearance of a spherical liquid region of radius r inside a superheated crystal, and (C) the temperature dependence of the nucleation rate R. All calculations are done with experimental thermodynamic properties of Au (31, 79).

Supplementary Material 2: Evolution of lattice and electron temperatures at  $\epsilon = 1.17$  MJ/kg  $(5.5\epsilon_m)$ , figure S2.

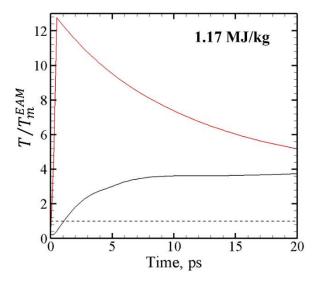
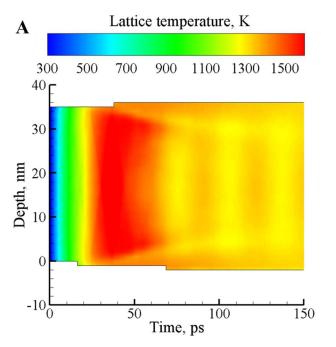
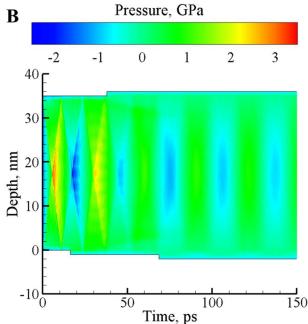


Figure S2. Evolution of lattice and electron temperatures at  $\varepsilon = 1.17$  MJ/kg (5.5 $\varepsilon_{\rm m}$ ). Average lattice (black) and electron (red) temperatures vs. time in a 35 nm Au film irradiated by a 130-fs laser pulse at an absorbed energy density of 1.17 MJ/kg (5.5 $\varepsilon_{\rm m}$ ). The temperatures are normalized by the equilibrium melting temperature at zero pressure of the model material,  $T_m^{EAM} = 1331$  K.

Supplementary Material 3: Temperature, pressure and phase state contour plots obtained in a TTM-MD simulation performed at  $\varepsilon = 0.21$  MJ/kg  $(0.99\varepsilon_{\rm m})$  with  $g = 2.3 \times 10^{16}$  Wm<sup>-3</sup>K<sup>-1</sup>, figure S3.





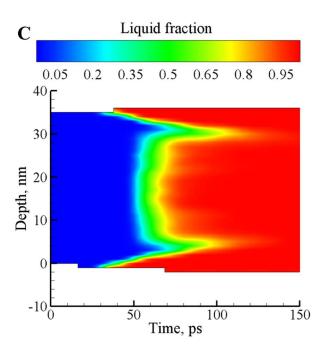


Figure S3. The evolution of temperature, pressure and phase state in a 35 nm Au film irradiated by a 130-fs laser pulse at an absorbed energy density of 0.21 MJ/kg. The contour plots show the spatial and temporal evolution of lattice temperature (A), pressure (B), and fraction of atoms in the liquid phase (C) predicted in a TTM-MD simulation performed with a constant value of electron-phonon coupling parameter,  $g = 2.3 \times 10^{16}$  Wm<sup>-3</sup>K<sup>-1</sup> obtained from the linear  $g(\varepsilon)$  dependence suggested in Ref. (22).

Supplementary Material 4: Snapshots of atomic configurations and the evolution of subcritical and supercritical crystalline regions in a TTM-MD simulation performed at  $\varepsilon = 0.20$  MJ/kg  $(0.94\varepsilon_m)$ , figures S4 and S5.

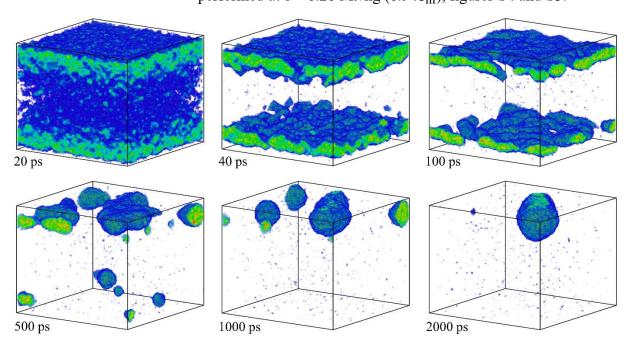


Figure S4. Atomic snapshots illustrating the melting process of a 35 nm Au film irradiated by a 130-fs laser pulse at an absorbed laser energy density of 0.2 MJ/kg (0.94 $\epsilon_{\rm m}$ ). The snapshots are from a TTM-MD simulation performed with  $g(T_e)$  from Ref. (29). The atoms that belong to the liquid phase are blanked, and the remaining atoms are colored according to the local order parameter, with color variation from blue to red for the local order parameter ranging from 0.04 to 1.

At an absorbed energy density of 0.2 MJ/kg, which is about 6% below the threshold for complete melting, the total number of atoms in the regions that remain crystalline decreases until about 2 ns, and then starts to increase, fig. S5A. This observation can be explained by the disintegration of the crystalline layers into separate regions during the first several hundreds of picoseconds after the laser pulse, fig. S4. The crystalline regions with effective diameters below  $D^* = (4\gamma_{LC}T_m)/(\Delta H_m\Delta T)$  are thermodynamically unstable at  $T = T_m - \Delta T$  (19) and disappear even though  $T < T_m$ . By the time of 1 ns, only three largest crystalline regions with effective diameters

of 9.8, 10.1, and 18.4 nm are present in the molten film. Note that some of the crystalline regions are split into two or three parts in the images shown in fig. S4 due the periodic boundary conditions.

The continuous crystalline regions are identified using cluster analysis implemented in OVITO (80) and the evolution of their sized is tracked from 1 ns to 2.5 ns with 20 ps intervals, as shown in fig. S5B. The temperature established in the film by 1 ns is about  $0.96T_m$ , and the undercooling of  $\Delta T = 0.04T_m$  corresponds to  $D^* = 11.2$  nm. The temperature and the corresponding value of  $D^*$  do not change significantly during the slow evolution of the phase composition of the film after 1 ns. As expected from the analysis of the thermodynamic stability of the crystalline regions, two smaller regions with  $D < D^*$  disappear by about 2 ns, while the largest region with  $D > D^*$  slowly grows in size, fig. S5B.

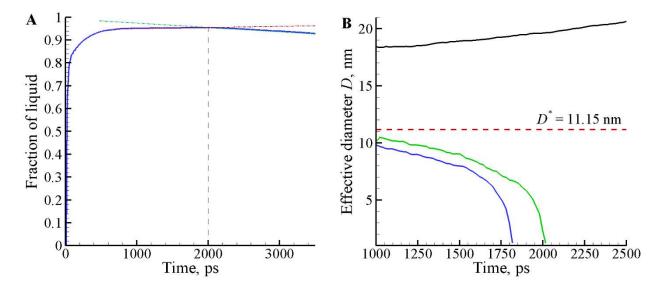


Figure S5. The long-term evolution of subcritical and supercritical crystalline regions in the simulation of melting of a 35 nm Au film irradiated by a 130-fs laser pulse at an absorbed energy density of 0.2 MJ/kg (0.94 $\varepsilon_{\rm m}$ ). The evolution of the fraction of atoms in the liquid phase is shown in (A), and the effective diameters of the three largest crystalline regions that remain in the film at 1 ns are plotted in (B). The vertical dashed line in (A) marks a time of 2 ns, when the melting turns into crystallization, as indicated by the green and red dash-dotted lines showing the approximate slopes of the melting curve before and after 2 ns, respectively. The horizontal dashed line in (B) marks the value of the theoretical critical diameter  $D^*$  calculated for the average temperature of the film,  $0.96T_m$ .

**Supplementary Material 5:** Tables of the melting times, electron-phonon coupling parameters, and electron temperature predicted in the TTM-MD simulations and obtained from the ultrafast electron diffraction experiments (22), tables S1, S2, and S3.

**Table S1.** The values of the melting times and electron-phonon coupling parameter predicted in the TTM-MD simulations and obtained from the ultrafast electron diffraction experiments (22).

Notation:  $\varepsilon$  – energy density deposited by the laser pulse;

 $\varepsilon_m$  – theoretical threshold energy density for complete melting of the Au film;

 $\tau_{start}$  and  $\tau_{end}$  – the times of the start and end of the melting process, defined as times when the fraction of atoms that belong to the liquid phase reaches the levels of 10% and 98%, respectively;

 $\tau_{end}^{exp}$  - time of melting reported in Ref. (22).

ε MJ/kg	$\epsilon/\epsilon_{ m m}$	TTM-MD with $g(T_e)$ (29)		TTM-MD with $g(\varepsilon)$			Exp. (22)
		$ au_{start},  ag{ps}$	τ <sub>end</sub> , ps	g from (22) 10 <sup>16</sup> Wm <sup>-3</sup> K <sup>-1</sup>	$ au_{end},$ ps	g fitted to $\tau_{end}^{exp}$ $10^{16} \mathrm{Wm^{-3}K^{-1}}$	$ au_{end}^{exp}$ , ps
0.18	0.85	43	-	2.20			
0.19	0.90	18.5	-	2.23			
0.195	0.92	17.5	-	2.24			
0.20	0.94	16.7	-	2.26			
0.21	0.99	15.5	56	2.29	115.4		
0.22	1.04	15	35	2.31	55.8		
0.23	1.08	13.75	21	2.34			
0.25	1.18	12.5	17	2.39			
0.30	1.42	9.75	13.75	2.53	34.1		
0.317	1.50	8.8	12.9	2.58	32.1	0.027	2500
0.36	1.70	7.5	11.75	2.70	26.3	0.074	800
0.40	1.89	6.5	11	2.80	23.6	1.44	45
0.50	2.36	5.2	9.4	3.08	19.4		
0.675	3.18	4.0	7.6	3.55	16.6	1.9	25
1.17	5.52	2.8	5.0	4.90	11.2	2.8	15

**Table S2.** The maximum values of  $T_e$  and the values of  $T_e$  at the end of the melting process in simulations performed with constant values of g fitted to the time of melting reported in Ref. (22),  $\tau_{end}^{exp}$ . The values of g are outlined by the red box in Fig. 9.

ε, MJ/kg	g fitted to $\tau_{end}^{exp}$ , $10^{16} \mathrm{Wm^{-3}K^{-1}}$	Maximum $T_e$ , $10^3 \cdot \text{K}$	$T_e$ at the end of melting, $10^3 \cdot \text{K}$
0.317	0.027	9.63	5.81
0.36	0.074	10.15	6.85
0.4	1.44	10.59	7.16
0.675	1.9	13.31	10.78
1.17	2.8	17.18	14.67

**Table S3.** The maximum values of  $T_e$  and the values of  $T_e$  at the end of the melting process in simulations performed using constant values of g suggested in Ref. (22). The values of g are outlined by the blue box in Fig. 9.

ε, MJ/kg	g from (22), 10 <sup>16</sup> Wm <sup>-3</sup> K <sup>-1</sup>	Maximum $T_e$ , $10^3 \cdot \text{K}$	$T_e$ at the end of melting, $10^3$ ·K
0.317	2.58	9.56	5.35
0.36	2.70	10.08	6.35
0.4	2.80	10.57	7.07
0.675	3.55	13.28	10.41
1.17	4.90	17.16	14.35

**Supplementary Material 6:** The results of TTM simulations with artificially increased electron-phonon coupling at surfaces of the film, figure S6.

The hypothesis that the slow melting dynamics can be attributed to the local enhancement of the strength of electron-phonon coupling due to the surface scattering is checked and discarded by performing two TTM simulations where the electron-phonon coupling is artificially increased by up to two orders of magnitude in 4-Å-wide layers adjacent to the free surfaces of the film. The TTM simulations are performed with the same parameters of the equation for the electron temperature, i.e.,  $c_e(T_e)$ ,  $g(T_e)$ , and  $k_e(T_e, T_l)$ , as those described in Materials and Methods in this article, and with the experimental temperature dependence of the lattice heat capacity,  $c_l(T_l)$  (31). The possibility of the homogeneous melting is not included in the simulations, but can be expected to occur within picoseconds after the temperature exceeds the limit of superheating,  $T^* \approx 1.25T_m$ , as discussed in Supplementary Material 1. The description of the kinetics of melting front propagation (heterogeneous melting) is incorporated into the model as described in Ref. (81). A linear dependence of the melting front propagation velocity on the superheating,  $v(T_l) = \mu(T_l - T_m)$ , where  $\mu = 0.39 \, \text{mK}^{-1} \text{s}^{-1}$  (82), is assumed in the simulations.

The temperature profiles predicted for the center of the film in the simulations performed for  $\varepsilon = 0.36$  MJ/kg with two values of electron-phonon coupling parameter assumed in the surface layers,  $g_s = 5 \times 10^{17} \ Wm^{-3}K^{-1}$  and  $g_s = 3 \times 10^{18} \ Wm^{-3}K^{-1}$ , are shown in Fig. S6. One can see that the enhancement of coupling at the two surfaces is indeed decreasing the heating rate in the center of the film due to a larger amount of energy deposited at the periphery. The enhanced coupling at the film surfaces, however, has a relatively weak effect on the time of melting. Similar to the TTM-MD simulation (Figs. 1A and 2A), the homogeneous melting is still predicted to occur by 10 ps after the laser pulse. If we neglect the possibility of the homogeneous melting, the two melting fronts would meet each other in the middle of the film at 68 to 79 ps, *i.e.*, completing the melting much earlier than the experimentally observed melting time of 800 ps (22).

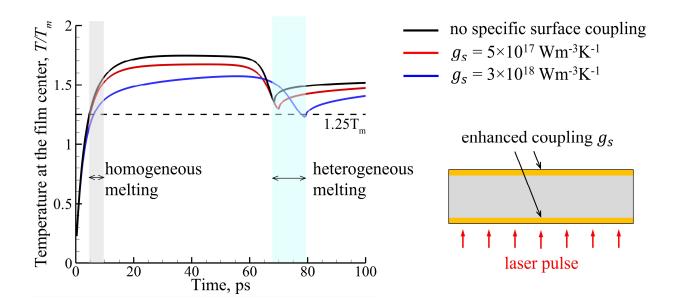


Figure S6. The results of the computational analysis of the effect of the increased electron-phonon coupling at surfaces of a 35 nm Au film irradiated by a 130-fs laser pulse. The plots show the evolution of temperature in the center of the film irradiated at an absorbed energy density of  $\varepsilon = 0.36$  MJ/kg, as predicted in TTM simulations performed with and without an artificially enhanced values of electron-phonon coupling in the surface regions. The gray and blue regions mark the timescales of the homogeneous melting at the limit of superheating and the heterogeneous melting under conditions when the homogeneous melting is neglected.

**Supplementary Material 7:** Evaluation of the effect of thermionic emission and multiphoton photoelectron emission on laser-induced melting.

The electron emission from the free surfaces of the Au film irradiated by the femtosecond laser pulse is a process that is not included in the TTM-MD model used in the simulations of laser-induced melting reported in the present paper. The assumption of the negligible role the electron emission plays in the melting process is verified by performing an order-of-magnitude estimation of the number of ejected electrons under irradiation conditions considered in the present study.

The estimation is performed by solving the TTM equations coupled with the description of the multiphoton photoelectron emission and thermionic emission. The large radius of the flat-top laser beam ( $R_0 = 210 \mu m$ ) and the small thickness of the Au film ( $h = 35 \mu m$ ) used in the experimental probing of the melting process (22) makes it possible to neglect the spatial dependence for electron and lattice temperatures in the model. The TTM equations in this case take the following form:

$$C_e(T_e)\frac{\partial T_e}{\partial t} = -g(T_e)(T_e - T_l) + \Sigma_{abs}(t)/h - Q_{loss}(T_e), \tag{S1}$$

$$C_l \frac{\partial T_l}{\partial t} = g(T_e)(T_e - T_l), \tag{S2}$$

where the electron temperature dependence of the electron heat capacity and electron-phonon coupling,  $C_e(T_e)$  and  $g(T_e)$ , are the same as those described in Materials and Methods in the article. Since the goal of the calculations is to obtain a rough order-of-magnitude estimate of the electron emission, we neglect the temperature dependence of the lattice heat capacity and use a room temperature value of  $C_l = 2.475 \times 10^6 \, \mathrm{Jm^{-3}K^{-1}}$  (31). The source term  $\Sigma_{abs}(t)$  represents the laser energy absorbed by the film per unit area and unit time. It is related to the incident laser intensity  $\Sigma(t)$  as  $\Sigma_{abs}(t) = (1 - R_{\omega})\Sigma(t)$ , where  $R_{\omega}$  is the reflectivity at a given laser wavelength. The laser intensity has a temporal Gaussian profile with the full width at half maximum equal to the laser pulse duration  $\tau_p = 130 \, \mathrm{fs}$ . To ensure the complete laser energy deposition, the laser pulse is shifted by  $2.5 \times \tau_p$  with respect to the start of the simulation.

The description of the total electron emission current density from each of the two surfaces of the film accounts for the contributions from the multiphoton and thermionic emission (83). At the experimental wavelength of 400 nm, the photon energy ( $\hbar\omega = 3.1 \text{ eV}$ ) is less than the work function of bulk gold,  $\phi = 4.8 \text{ eV}$  (84), so two- and three-photon photoemission should have the

most significant influence. The two- and three-photon generated electron current density is described by the model based on the Fowler-DuBridge theory (83, 85):

$$J_{2p} = a_{2p} A_0 \left( \left( \frac{e}{\hbar \omega} \right) (1 - R_\omega) \right)^2 T_e^2 F(X_{2p}) \Sigma(t)^2, \tag{S3}$$

$$J_{3p} = a_{3p} A_0 \left( \left( \frac{e}{\hbar \omega} \right) (1 - R_\omega) \right)^3 T_e^2 F(X_{3p}) \Sigma(t)^3, \tag{S4}$$

where F(x) is the Fowler function (85, 86),  $R_{\omega}$  is the reflectivity at a given laser wavelength,  $A_0 = 120 \,\mathrm{A\,cm^{-2}K^{-2}}$  is the Richardson coefficient, e is the elementary charge,  $a_{2p}$  and  $a_{3p}$  are material-dependent coefficients, which correspond to the two- and three-photon emission, respectively,  $X_{2p} = (2\hbar\omega - \tilde{\phi} + \mu(T_e) - E_f)/k_BT_e$ ,  $X_{3p} = (3\hbar\omega - \tilde{\phi} + \mu(T_e) - E_f)/k_BT_e$ . Here,  $\mu(T_e) - E_f$  is the chemical potential that accounts for the significant change in the effective Fermi energy level caused by the thermal excitation of the d-band electrons at high  $T_e$  (29).

The coefficients  $a_{2p}$  and  $a_{3p}$  are calculated using relationships between the electron current density and the intensity of incident nanosecond laser pulses determined in experiments reported in Ref. (84). The proportionality coefficients for two- and three- photon emission obtained in the experiments are  $2.4 \times 10^{-3}$  (A cm<sup>-2</sup>)/(MW cm<sup>-2</sup>)<sup>2</sup> and  $1 \times 10^{-7}$  (A cm<sup>-2</sup>)/(MW cm<sup>-2</sup>)<sup>3</sup> at laser wavelengths of 347.2 and 694.3 nm, respectively. Based on values of reflectivity  $R_{\omega}$  at these wavelengths, 0.3853 and 0.9695 (87), and using Eqs. (S3) and (S4), we obtain the coefficients  $a_{2p} = 1.827 \times 10^{-32}$  (m<sup>2</sup>/A)<sup>2</sup> and  $a_{3p} = 7.974 \times 10^{-42}$  (m<sup>2</sup>/A)<sup>3</sup>. The term  $\tilde{\phi}$  is a work function modified to account for the space charge effect as discussed below.

The thermionic emission is described by the Richardson-Dushman equation based on the free electron gas model (63):

$$J_t = A_0 T_e^2 \exp\left(-\frac{\tilde{\phi} - (\mu(T_e) - E_f)}{k_B T_e}\right). \tag{S5}$$

The total electron emission from each of the two surfaces of the film is  $J_S = J_{2p} + J_{3p} + J_t$ . Since the optical penetration depth is comparable with the film thickness and the film is uniformly heated by the laser pulse, the emission from the front and back surfaces of the film can be assumed to be approximately the same. Thus, the total electron current density calculated in the simulation is  $J_{Tot} = 2J_S$ . The corresponding numbers of emitted electrons per unit volume of the Au film per

unit time are calculated from the continuity equations,  $dn_e^{2p}/dt = 2J_{2p}e^{-1}h^{-1}$ ,  $dn_e^{3p}/dt = 2J_{3p}e^{-1}h^{-1}$ ,  $dn_e^t/dt = 2J_te^{-1}h^{-1}$ , and  $dn_e^{Tot}/dt = J_{Tot}e^{-1}h^{-1}$ .

As discussed in (88), each thermionically emitted electron on average carries an energy of  $\tilde{\phi}$  +  $E_f - \mu(T_e) + k_B T_e$ . Thus, the energy loss due to thermionic emission is

$$Q_{loss}^{t}(T_{e}) = A_{0}e^{-1}T_{e}^{2}\left(\tilde{\phi} - (\mu(T_{e}) - E_{f}) + k_{B}T_{e}\right)\exp\left[-\frac{\tilde{\phi} - (\mu(T_{e}) - E_{f})}{k_{B}T_{e}}\right],$$
 (S6)

and the total energy loss term present in the TTM equation for  $T_e$  can be written as

$$Q_{loss}(T_e) = Q_{loss}^t(T_e)/h + 2\hbar\omega \times \partial n_e^{2p}/\partial t + 3\hbar\omega \times \partial n_e^{3p}/\partial t, \tag{S7}$$

The space charge generated by emitted electrons is known to significantly affect the number of escaped electrons (63, 64). To account for this effect, we follow an approximate treatment of the extra energy barrier for the emission of a new electron produced by the cloud of already escaped electrons suggested in Ref. (63). Within this treatment, the extra energy barrier is introduced through the modification of the work function,

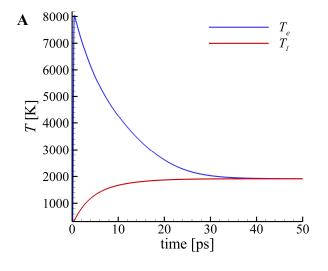
$$\widetilde{\phi} = \phi + a \frac{e^2 n_e^{Tot}(t) \times S \times h}{2\varepsilon_0 R_0}, \tag{S8}$$

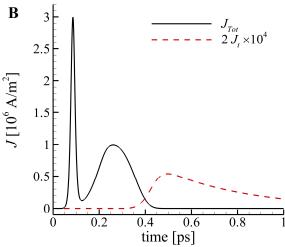
where  $n_e^{Tot}(t)$  is the cumulative number of electrons per unit volume emitted by time t,  $\varepsilon_0$  is the permittivity of vacuum, and  $S = \pi R_0^2$ , is the area of the laser spot. Coefficient a describes the geometry of the electronic cloud and is assumed here to be 1.7, which corresponds to a thin disk (63). The factor of 2 in the denominator of Eq. (S8) is related to the fact that only half of the ejected electrons,  $n_e^{Tot}(t)$ , contributes to the extra energy barrier at each surface of the film. While a more accurate treatment of the evolution of the cloud of emitted electrons above the target surface is possible in particle-in-cell (PIC) simulations (64), the analytical approximation described above has been shown to provide a good quantitative description of the electron emission in experiments performed for several metals (63, 68). The neglect of the space charge effect has been demonstrated to result in an overestimation of the number of electrons emitted through both the thermionic and multiphoton mechanisms by several orders of magnitude (63, 64).

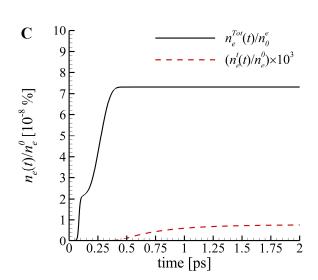
To evaluate the possible effect of the multiphoton and thermionic emission on the melting behavior analyzed in the present paper, we apply the model described above to estimate the number of electrons emitted from a 35-nm-thick Au film irradiated by a 130 fs at an energy density that

corresponds to the threshold for complete melting,  $\varepsilon_m = 0.212 \,\mathrm{MJ/kg}$ . The initial density of conduction band electrons,  $n_e^0 = 5.91 \times 10^{28} \mathrm{m}^{-3}$ , is calculated by assuming one conducting electron per Au atom.

The results of the simulation are illustrated by Fig. S7. The rapid build-up (within 0.4 ps) of the space charge due to photoemission leads to the buildup of the repulsive electrostatic potential up to 15.3 V, the level similar to that predicted in PIC simulations performed for Cu (64). This potential suppresses further emission, with the electron emission current density due to multiphoton emission exhibiting a pronounced dip at  $\sim 0.125$  ps and a partial transient recovery produced by the competition between an increase in the effective work-function  $\tilde{\phi}$  and a simultaneous increase in the electron temperature, fig. S7B. Since the model does not include any sinks for the emitted electrons, the final fraction of emitted electrons is mostly defined by the two-and three- photon photoemission rather than a longer-term thermionic contribution. The total number of the emitted electrons does not exceed  $10^{-7}\%$  of the total number of conduction band electrons, fig. S7C. Such a small fraction of emitted electrons is unlikely to have any effect on the magnitude of the electron-phonon coupling or affect lattice stability against melting. The total energy loss due to electron emission is found to be on the order of  $\sim 10^{-3}$ J/kg, and the effect of this energy loss on the electron temperature is negligible.







estimation of the electron emission from a 35 nm Au film irradiated by a 130-fs laser pulse. The simulation is performed at an energy density that corresponds to the threshold for the complete melting of the film. The evolution of electron (black line) and lattice (red line) temperatures is shown in (A). The total electron current density (black line) and the thermionic contribution (red dashed line) are shown in (B). The total

number of emitted electrons (black line) and fraction of electrons emitted due to the thermionic emission only (red dashed line) are shown in (C). The thermionic current density and the corresponding number of emitted electrons are multiplied by  $\times 10^4$  and  $\times 10^3$ , respectively, for scaling in (B) and (C).

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